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(54) Title: METHOD FOR PRESERVING ORGANIC POLYMERIC MATERIAL AND ORGANIC ELECTROLUMINESCENT **DEVICE** 

(57) Abstract: A method for preserving an organic polymeric material, wherein an organic polymeric material which exhibits strong acidity is preserved with it being dissolved or dispersed in a liquid mainly comprised of water, the method is characterized in that the organic polymeric material is preserved with it being dissolved or dispersed in the liquid so that a concentration thereof is 2 wt%, and a pH (at 25°C) of the thus obtained liquid is measured and then adjusted so as to be to be higher than the measured pH (at 25°C). Further, it is preferred that a pH (25°C) of the liquid before the pH adjustment is 2.2 or lower and a pH (25°C) of the liquid after the pH adjustment is in the range of 2.5 to 7.5. According to this, even if the organic polymeric material is preserved for a long period of time, it is possible to prevent or reduce a change in a molecular structure thereof with the lapse of time.

